

Title (en)
NASAL MASK FOR VENTILATION

Title (de)
NASENMASKE FÜR VENTILATION

Title (fr)
MASQUE NASAL DESTINÉ À ASSURER UNE VENTILATION

Publication
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Application
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Abstract (en)
[origin: EP2000167A2] According to the present invention, there is provided a nasal respiratory mask contacting with the face of a user for supplying respiratory positive-pressure gas to the nose of the user, comprising at least a part attached tightly to the face that is attached tightly to the face of the user; a frame-fitting part for fitting to a frame; and an elastic connecting part that connects elastically the part attached tightly to the face with the frame-fitting part, wherein a facial side of the elastic connecting part is kept apart from the frame-fitting part side thereof for a required distance even in the absence of applied respiratory positive pressure. The nasal respiratory mask has advantages that it can be worn in an appropriate position without applying positive pressure at the start of wearing, scarcely disturbs the visual field during wearing, and can prevent prolongation of the time required for drying or occurrence of unsanitary condition after routine cleaning by washing with water.

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Citation (search report)
• [XII] WO 2005123166 A1 20051229 - RESMED LTD [AU], et al
• [XI] WO 2004022146 A1 20040318 - RESMED LTD [AU], et al

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JP 4547027 B2 20100922; JP WO2007111374 A1 20090813; KR 20080100485 A 20081118; MY 147457 A 20121214;
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